

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent of:)
KOHEI OKAMOTO ET AL.) : Examiner: Ben Loha
Appln. No.: 10/573,308) : Art Unit: 2873
Filed: September 30, 2004) : Conf. No.: 1990
For: PROCESS FOR PRODUCING)
THREE-DIMENSIONAL STRUCTURE)
U.S. Patent No.: 7,408,692 B2)
Issued: August 5, 2008 : October 30, 2008

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

CERTIFICATE OF CORRECTION
UNDER RULES 322 AND 323

Sir:

It is respectfully requested that a Certificate of Correction be issued by the Patent and Trademark Office due to errors, which appear in the printed patent as a result of Patent and Trademark Office mistakes, and mistakes of a clerical, typographical, or minor character, which were not the fault of the Patent and Trademark Office. A Certificate of Correction form is attached.

The amount of \$100.00 to cover the statutory fee for such Certificate of Correction is being paid concurrently; please charge any deficiency in the fee, and credit any overpayment, to Deposit Account 06-1205.

Patentees' undersigned attorney may be reached in our New York office by telephone at (212) 218-2100. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

/Jason M. Okun/
Jason M. Okun
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FCHS_WS 2605627v1

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : US 7,408,692 B2

DATED : August 5, 2008

INVENTOR(S) : KOHEI OKAMOTO ET AL.

Page 1 of 2

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

ON THE TITLE PAGE [56] REFERENCES CITED:

OTHER PUBLICATIONS, insert: --V. Mizeikis et al., "Femtosecond Laser Microfabrication of Photonic Crystal Structures by Glass Damaging and Resin Photosolidification," *Proceedings of the 4th Pacific Rim Conference on Lasers and Electro-Optics*, vol. 1, pp. I-302 - I-303 (July 2001).--, and insert: --Xuan-Ming Duan et al., "Micron/Nanofabrication of Two and Three Dimensional Structures by Two-Photon Polymerization," *Proceedings of the 2003 Third IEEE Conference on Nanotechnology*, pp. 498-501 (August 2003).--.

COLUMN 2:

Line 10, "are" should be deleted.

COLUMN 3:

Line 15, "order" (second occurrence) should read --order of--.

COLUMN 6:

Line 14, "word," should read --words,--.

COLUMN 7:

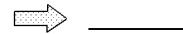
Line 64, "unit light-concentrating means" should be deleted.

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Page 2 of 2

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

COLUMN 10:

Line 14, "is" should read --are--.

COLUMN 12:

Line 14, "light" (second occurrence) should read --a light--.

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